

Supporting Information

Metallic-like bonding in plasma-born silicon nanocrystals for nanoscale bandgap engineering

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Abstract

Based on *ab initio* molecular dynamics simulations, we show that small nanoclusters of about 1nm size spontaneously generated in a low-temperature silane plasma do not possess tetrahedral structures, but are ultrastable. Apparently small differences in cluster structure result in substantial modifications in their electric, magnetic, and optical properties without the need for any dopants. Their nontetrahedral geometries notably lead to electron deficient bonds that introduce efficient electron delocalization that strongly resembles the one of a homogeneous electron gas leading to metallic-like bonding within a semiconductor nanocrystal. As a result, pure hydrogenated silicon clusters that form by self-assembly in a plasma reactor possess optical gaps covering most of the solar spectrum from 1.0 eV to 5.2 eV depending simply on their structure and, in turn, on their degree of electron delocalization. This feature makes them ideal candidates for future bandgap engineering not only for photovoltaics, but also for many nano-electronic devices employing nothing else but silicon and hydrogen atoms.

**Cartesian coordinates of the Si₁₉H₁₂ isomer D
after MP2/6-311++G(d,p) optimization**

Si -0.97871 -0.69367 2.72395
Si -2.17782 1.13100 1.78639
Si -0.61780 2.68206 0.93356
Si 1.51409 2.00584 1.74546
Si 1.33704 -0.18319 2.63156
Si -1.32485 -2.55830 1.32264
Si -3.57038 0.47237 0.00455
Si -0.73877 2.61278 -1.44062
Si 2.93131 1.85340 -0.10200
Si 2.49204 -1.64381 1.18345
Si 1.25921 1.40464 -1.67144
Si -1.61599 -1.00391 -2.00989
Si -2.87936 -1.77085 -0.23711
Si 0.68319 -2.64132 0.04600
Si 2.17028 -0.55142 -2.51620
Si 0.43077 -2.21637 -2.31585
Si -2.53680 1.18449 -1.99597
Si 0.10096 -0.38485 -0.50620
Si 3.52404 -0.39623 -0.50944
H -1.38754 -0.88628 4.14259
H -2.99104 1.76157 2.86255
H -0.92234 4.04849 1.44150
H 1.97318 2.95953 2.78942
H 1.89104 -0.19875 4.01389
H -1.67586 -3.83590 1.98672
H -5.01377 0.72842 0.22502
H -0.76928 3.94646 -2.09622

H 3.88748 2.95137 -0.37517

H 3.38993 -2.60644 1.86887

H -3.39099 1.65023 -3.11450

H 4.94823 -0.73343 -0.74300